

COMBINATION LOOP TEXTILE

Background

The present invention generally relates to textiles having loops extending outwardly from a base material.

- 5 Loop textiles have many applications. As an example, terry cloth loop textiles have been used for cleaning purposes. However, the terry cloth loops do not always provide a surface sufficient for scrubbing a surface. Therefore, there is a need for loop textiles having different characteristics for engaging another item.

10 Brief Description Of The Drawings

FIG. 1 is a cross-sectional view of an embodiment of the present invention, illustrated as a loop textile.

FIG. 2 is a cross-sectional view of another embodiment of the present invention.

- 15 FIG. 3 is a cross-sectional view of yet another embodiment of the present invention.

FIG. 4A-F are enlarged cross-sectional views of a filament from a loop of the textile in FIGS. 1-3.

- 20 FIG. 5 is a block diagram illustrating one embodiment of a method for forming the loop textiles in FIGS. 1-3.

Detailed Description

- Referring now to the figures, and in particular to FIGS. 1-3, there is shown a cross-sectional view of various embodiments of the present invention, illustrated as the loop textiles 10, 20, and 30. The textiles 10, 20
25 and 30, generally include a base substrate 100 with a first surface 110 and a second surface 120, a plurality of first and second receiving loops 210, 220

extending from the base substrate 100, and a plurality of first and second stiff loops 310, 320 extending from the base substrate 100.

As illustrated in FIGS. 1-3, the base substrate 100 is a knitted cloth formed from a plurality of substrate yarns 101. Although the base substrate 100 is illustrated in FIGS. 1-3 as a knitted cloth, the base substrate 100 can be any material that provides a flexible cloth-like base from which the loops 210, 220, 310, 320 can extend. For example, the base substrate can also be woven, non-woven, foam (open or closed cell), film, or any other similar web-like material. In one embodiment, the base substrate 100 is absorbent. In another embodiment, the base substrate 100 can receive particles.

The first receiving loops 210 are a yarn that originate and extend outwardly from the first surface 110 of the base substrate 100, and return into the first surface 110 of the base substrate 100. The second receiving loops 220 are a yarn that originate and extend outwardly from the second surface 120 of the base substrate 100, and return into the second surface 120 of the base substrate 100. In one embodiment, the height (h) of the receiving loop 210, 220 is between about 0.1 millimeter and about 5 millimeters, and the width (w) of the receiving loop 210, 220 is between about 0.1 millimeters and about 5 millimeters at the widest point. In another embodiment, the height (h) of the receiving loop 210, 220 is between about 0.3 millimeter and about 3 millimeters, and the width (w) of the receiving loop 210, 220 is between about 0.3 millimeters and about 3 millimeters at the widest point. In a particular embodiment, the receiving loop 210, 220 extends to a height (h) of about 0.8 millimeters from the base substrate 100, and is about 1.0 millimeter wide (w) at the widest point.

The receiving loops 210, 220 are absorbent and/or retain particles. In one embodiment, the yarn forming the first and second receiving loops 210, 220, is the same yarn as the substrate yarn 101 forming the base substrate 100. In another embodiment, the yarn forming the first and second receiving loops 210, 220, can be a different yarn than the substrate yarn 101 forming

the base substrate 100. The yarn forming the receiving loops 210, 220 can be filament or staple yarns, textured or non-textured, and include an appropriate surface finish. The receiving loops 210, 220 have a denier per yarn of greater than about 10 in one embodiment, and greater than about 20
5 in another embodiment. The receiving loops 210, 220 also have a denier per yarn of less than about 1000 in one embodiment, and less than about 500 in another embodiment. In one embodiment, the receiving loops 210, 220 can have from 10 to 10,000 filaments per yarn, and at least one of the filaments can range from about 0.01 to about 5 denier per filament. In another
10 embodiment, the receiving loops 210, 220 have at least one filament with a denier per filament of less than about 1.

The first stiff loops 310 are a yarn that originate and extend outwardly from the first surface 110 of the base substrate 100, and return into the first surface 110 of the base substrate 100. The second stiff loops 320 are a yarn
15 that originate and extend outwardly from the second surface 120 of the base substrate 100, and return into the second surface 120 of the base substrate 100. The stiff loops 310, 320 have a height and width that is generally sufficient to receive material within the stiff loops 310, 320 when the textile 10, 20, 30 passes over another surface. In one embodiment, the height (h) of the
20 stiff loop 310, 320 is between about 0.1 millimeter and about 5 millimeters, and the width (w) of the stiff loop 310, 320 is between about 0.1 millimeters and about 5 millimeters at the widest point. In another embodiment, the height (h) of the stiff loop 310, 320 is between about 0.3 millimeter and about 3 millimeters, and the width (w) of the stiff loop 310, 320 is between about 0.3
25 millimeters and about 3 millimeters at the widest point. In a particular embodiment, the stiff loop 310, 320 extends to a height (h) of about 1.0 millimeters from the base substrate 100, and is about 0.8 millimeter wide (w) at the widest point.

As illustrated in FIGS. 1-3, the stiff loops 310, 320 are a mono-filament
30 yarn. However, it is contemplated that the yarn forming the stiff loops 310,

320 can be either a mono-filament yarn or a multiple filament yarn. In one embodiment, the yarn forming the stiff loops 310, 320 has at least one filament with a denier per filament of at least about 10. In another embodiment the yarn forming the stiff loops 310, 320 have at least one
5 filament with a denier per filament of at least about 20. In one embodiment the yarn forming the stiff loops 310, 320 have a denier per yarn of no greater than about 500 in one embodiment, and about 1000 in another embodiment.

Referring now to FIG. 4A-F, there are shown enlarged cross-section of various embodiments of filaments that can be used in the yarn of the stiff
10 loops 310, 320 from FIGS. 1-3. The cross-section of the filaments used in the yarn of the stiff loops 310, 320 can be circular, or as shown in FIGS. 4A-F, or another cross-section. In FIG. 4A is illustrated a filament having an elliptical cross-section. In FIG. 4B is illustrated a filament having a rectangular cross-section. In FIG. 4C is illustrated a filament having a square cross-section. In
15 FIG. 4D is illustrated a filament having a tear drop shaped cross-section. In FIG. 4E is illustrated a filament having a crescent shaped cross-section. In FIG. 4F is illustrated a filament having a multi-lobe cross-section, such as a tri-lobe.

In one embodiment, the cross-section of the filament(s) forming the stiff
20 loops 310, 320 have an aspect ratio of greater than 1.2, as illustrated in FIGS. 4A-F. As used herein an aspect ratio shall mean the width of the cross-section at its widest point divided by the width of the cross-section at its narrowest point. In another embodiment, the cross-section of the filament(s) forming the stiff loops 310, 320 have at least one corner edge, as illustrated in
25 FIGS. 4B-F. In yet another embodiment, the cross-section of the filament(s) forming the stiff loops 310, 320 have a cross-section with at least a portion of the cross-section being concave, as illustrated in FIGS. 4E-F. As used herein, concave shall mean a shape that the outer perimeter extends within a straight line drawn between any two points on the outer perimeter.

In an embodiment where the stiff loops 310, 320 are formed of mono-filament yarns, the cross sections of the filaments can either be all one type of cross-section, or multiple cross-sections can be used for the filaments forming the various stiff loops 310, 320. In an embodiment where the loops are
5 formed of multiple filament yarns, the cross sections of the filaments forming the yarns can either be all of one type of cross-section (homogeneous), or multiple types of cross-sections (heterogeneous). Additionally, the various stiff loops 310, 320 can be yarns of different filaments, including any combination of homogenous yarns and/or heterogeneous yarns.
10 Furthermore, the various stiff loops 310, 320 can be combinations of any of the mono-filament yarns and multiple filament yarns.

Referring back now to FIGS. 1-3, the yarn forming the stiff loops 310, 320 can be stiffer than the material of the base substrate 110. The yarn forming the first and second stiff loops 310, 320 can also be stiffer than the
15 material of the receiving loops 210, 220. In one embodiment, filaments forming the stiff loops 310, 320 are at least about a 10 denier per filament size larger than the filaments forming the receiving loops 210, 220.

The textile 10, 20, 30 having the two type of loops 210, 220, and 310, 320, can be imparted with favorable absorbency characteristics. Absorbency
20 is defined by the mass of water absorbed by a textile per mass of textile. A common test procedure for this characteristic is the Institute of Environmental Science & Technology (IEST), Control Division Recommended Practice 004.2, test IEST-RP-CC004.2, "Evaluating Wiping Materials Used in Cleanrooms and Other Controlled Environments". In one embodiment, the
25 textile 10, 20, 30 has an absorbency rate of at least about 2 grams of water per gram of textile. In another embodiment, the textile 10, 20, 30 has an absorbency rate of at least about 2.5 grams of water per gram of textile. In yet another embodiment, the textile 10, 20, 30 has an absorbency rate of at least about 3 grams of water per gram of textile.

Referring now to FIG. 1, the first receiving loops 210 and the first stiff loops 310 originate at about the same location in the first side 110 of the base substrate 100, and return to the first side 110 of the base substrate 100 at about the same location as each other. Similarly, the second receiving loops 220 and the second stiff loops 320 originate at about the same location in the second side 120 of the base substrate 100, and return at about the same location in the second side 120 of the base substrate 100 as each other. Although the loop textile 10 has been illustrated in FIG. 1 with receiving loops 210, 220 and stiff loops 310, 320 on both sides 110, 120 of the base substrate 100, it is contemplated that the present invention may have only receiving loops 210 and stiff loops 310 on the first side 110, receiving loops 210 and stiff loops 310 on the first side 110 with only receiving loops 220 on the second side 120, receiving loops 210 and stiff loops 310 on the first side 110 with only stiff loops 320 on the second side 120, or only receiving loops 210 on the first side 110 with only stiff loops 320 on the second side 120.

Referring now to FIG. 2, the first receiving loops 210 and the first stiff loops 310 originate in the first side 110 of the base substrate 100 and return into the first side 110 of the base substrate 100. The first receiving loops 210 can originate and return adjacent to each other, or adjacent to first stiff loops 310. Similarly, the first stiff loops 310 can originate and return adjacent to each other, or adjacent to first receiving loops 210. The second receiving loops 220 and the second stiff loops 320 originate in the second side 120 of the base substrate 100 and return to the second side 120 of the base substrate 100. The second receiving loops 220 can originate and return adjacent to each other, or adjacent to second stiff loops 320. Similarly, the second stiff loops 320 can originate and return adjacent to each other, or adjacent to second receiving loops 220. Although the loop textile 20 has been illustrated in FIG. 2 with receiving loops 210, 220 and stiff loops 310, 320 on both sides 110, 120 of the base substrate 100, it is contemplated that the present invention may have only receiving loops 210 and stiff loops 310 on

the first side 110, receiving loops 210 and stiff loops 310 on the first side 110 with only receiving loops 220 on the second side 120, receiving loops 210 and stiff loops 310 on the first side 110 with only stiff loops 320 on the second side 120, or only receiving loops 210 on the first side 110 with only stiff loops 320 on the second side 120.

Referring now to FIG. 3, the first receiving loops 210 and the first stiff loops 310 originate in the first side 110 of the base substrate 100 and return into the first side 110 of the base substrate 100. The first receiving loops 210 can originate and return adjacent to each other, or adjacent to first stiff loops 310. Similarly, the first stiff loops 310 can originate and return adjacent to each other, or adjacent to first receiving loops 210. However, the second receiving loops 220 and the second stiff loops 320 originate at about the same location in the second side 120 of the base substrate 100, and return at about the same location in the second side 120 of the base substrate 100 as each other. Although the loop textile 30 has been illustrated in FIG. 3 with receiving loops 210, 220 and stiff loops 310, 320 on both sides 110, 120 of the base substrate 100, it is contemplated that the present invention may have only receiving loops 210 and stiff loops 310 on the first side 110, receiving loops 210 and stiff loops 310 on the first side 110 with only receiving loops 220 on the second side 120, receiving loops 210 and stiff loops 310 on the first side 110 with only stiff loops 320 on the second side 120, or only receiving loops 210 on the first side 110 with only stiff loops 320 on the second side 120.

Additionally, it is anticipated that the present invention can be a textile that has sections according to the textile 10 in FIG. 1 and sections according to the textile 20 in FIG. 2 on either side, or both sides, of the textile. Also, it is anticipated that the receiving loops 210, 220 can be smaller, larger, or the same size as the stiff loops 310, 320, in height and/or width.

Referring now to FIG. 5, there is shown a block diagram of a method 500 of forming one embodiment of the textile according to any one of FIGS. 1-3. The method 500 illustrated in FIG. 5 generally includes the steps of

acquiring a sheet of polymer material 510, slitting the sheet of polymer material into strips 520, acquiring a receiving yarn 530, and forming a base substrate and attaching the strips of polymer to the base substrate as stiff loops extending from the base substrate and attaching the receiving yarn to the base substrate as receiving loops extending from the base substrate 540.

In step 510, the acquired sheet of polymer material can be a polymer that is extruded, cast, blown, or that is formed in any other manner that produces a sheet of polymer. The polymer can be polyethylene, polyester, polypropylene, or the like. The thickness of the sheet can be from about 0.0005 inches to about 0.005 inches. In one embodiment, the film is about 0.0015 inches thick.

In step 520, the sheet of polymer material is slit into individual filaments. In one embodiment, a long sheet of polymer material is unrolled and engages a row of knives that slit the sheet of polymer from its original width to many strips of the polymer material, the number of strips determined by the number of knives. The width of the filaments can be from about 0.002 inches to about 0.25 inches. In one embodiment, the individual filaments are strips of polymer that are about 0.0145 inches wide.

In step 540, the forming a base substrate and attaching the strips of polymer and receiving yarn can be performed by double knitting the base substrate, tucking the strips of polymer and receiving yarn into the base substrate, and knitting the polymer strips and receiving yarn into the base substrate as loops. In one embodiment, the polymer strips and receiving yarn are attached as loops to the base substrate by attaching a first section of the strip of polymer and the receiving yarn to the base substrate 541, bringing the strip of polymer and receiving yarn around sacrificial yarn, attaching a second section of the strip of polymer and receiving yarn to the base substrate on the opposite side of the sacrificial yarn from the first section of the strip of polymer and receiving yarn 542, and removing the sacrificial yarn from between the base substrate and the strip of polymer and receiving yarn to form a stiff loop

of the strip of polymer and a receiving loop of the receiving yarn 543. In a further embodiment, the step of removing the sacrificial yarn is performed by dissolving the sacrificial yarn.

The present invention can also be better understood by reference to the following example. A polymer sheet was acquired of a polyester film being about 0.0015 inches thick. The polymer sheet was slit into filament strips of about 0.0145 inches wide. A base substrate was formed from a substrate yarn of textured filament polyester yarn, having 34 filaments per yarn at a yarn denier of 150 (such as Dacron 56T by DuPont). The filament polymer strips were attached to the base substrate as stiff loops by tucking the filament polymer strips into a first side of the base substrate as it was being formed, and knitting the filament polymer strips into the base substrate around a one ply, 40 denier per filament, 12 filament sacrificial water-soluble poly(vinyl alcohol) yarn (such as Solvron by Nitivy) on the first side of the base substrate. A soft yarn of splittable of Nylon/PET, 150 denier per yarn, 48 filament (splittable into $48 \times 11 = 528$ filaments) (such as Wramp by Kuraray), was attached to the base substrate as receiving loops by tucking the soft yarn into a second side of the base substrate as it was being formed, and knitting the soft yarn into the base substrate around a one ply, 40 denier per filament, 12 filament sacrificial water-soluble poly(vinyl alcohol) yarn (such as Solvron by Nitivy) on the second side of the base substrate. The sacrificial yarn was removed by immersing the textile into a hot water scour of 160F. After formation of the loops by dissolving the sacrificial yarn, the textile was dyed, slit to proper width, dried, and cut to the appropriate size. The textile according to this first example had an absorbency of about 3 grams of water per gram of textile.

In a second example, the first example was formed with an additional soft yarn being attached and knitted into the base substrate as receiving loops on the same side of the base substrate as the stiff loops. The textile according to this second example had an absorbency of about 4 grams of

Inventor: Morin et al.
Express Mail Label No. EL 782283089 US

US PTO Customer No. 25280
Case No. 5150

water per gram of textile.